

Sheet 1 of 1

Form PTO-100 (REV. 8-83)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 106452		APPLICATION NO. 10/046,245	
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)							
				APPLICANT(S) Cathie J. BURKE et al.			
				FILING DATE January 16, 2002		GROUP 1756	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	
DLD		5,344,748	9/1994	Feely	430	330	
DLD		5,738,799	4/1998	Hawkins et al.	216	27	
DLD		5,485,181	1/1996	Convers	347	63	
DLD		5,699,094	12/1997	Burke et al.	347	63	
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)							
DLD		S. Hagan et al., "Photosensitive Polyimide: Lithography in the Thick-Film Regime," Proceedings 11 th International Conference Photopolymers Principles, Processes, and Materials, Society of Plastics Engineers, Inc., Oct. 6-8, 1997, p. 422-437					
EXAMINER	<i>Deborah L. Hagan</i>				DATE CONSIDERED <i>11/17/2003</i>		
Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							

Date: April 9, 2002